



COPPER-MEDIATED ELECTROPHILIC TRIFLUOROMETHYLATION OF AMINES

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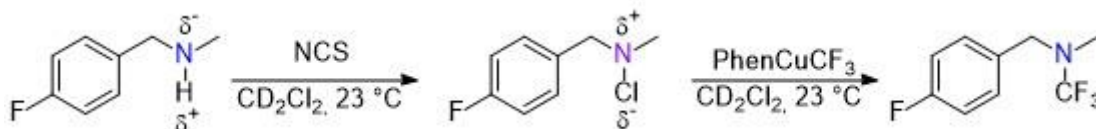
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The trifluoromethyl group improves the lipophilicity and helps crossing biological barriers. Such properties make it an asset for the activity of drugs, in which the CF₃ moiety is, in most cases, bounded to a carbon atom,¹ albeit O–CF₃² and S–CF₃³ linkages can also be found.

In contrast, despite the ubiquity of nitrogen atoms in drugs, N–CF₃ groups are rarer, notably because of the difficulty to form those bonds. It appears that a direct trifluoromethylation of free amines is difficult.⁴ Thus, N–CF₃ bonds are generally formed by *de novo* syntheses using the natural nucleophilicity of the nitrogen atom.^{5,6,7} The incorporation of a CF₃ as a whole adduct would require finding a new reactivity.

In this work, we used chloramines and their electrophilic nitrogen atoms coupled with a nucleophilic CF₃ source to form the N–CF₃ bond. The Ruppert-Prakash's reagent^{8,9} in the presence of a fluoride source resulted mainly in gaseous CF₃Cl. In contrast, an alternative source of nucleophilic CF₃, [(phen)CuCF₃] (phen = 1,10-Phenanthroline)¹⁰ was used and enabled the formation of the desired amine. We then developed a one-pot two-steps synthesis of trifluoromethylamines from free amines in 30 minutes at room temperature using *N*-chlorosuccinimide (NCS) as the chlorinating agent. The mechanism has also been studied with DFT calculations and electrochemical analyses.



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